

Amendments to the Claims:

This listing of claims replaces all prior versions and listings of claims in the application:

Listing of Claims:

1-16. (Cancelled)

17. (Previously presented) A method of making a cutting element for a safety razor blade unit comprising the steps of providing a wafer of single crystal material having a surface lying in a predetermined plane of the crystallographic structure, selectively removing crystal material at the surface by employing an etching process to form a planar cutting element inclined at an acute angle to the surface plane and having a sharp cutting edge substantially at the surface plane, and forming a guard element from the wafer of single crystal material by the etching process, said guard element being disposed substantially parallel to the cutting edge and spaced forwardly therefrom and being integrally connected to the cutting element by interconnecting elements.

18. (Original) A method according to claim 17, wherein the etching process comprises anisotropic wet chemical etching.

19. (Previously presented) A method according to claim 17, wherein the etching process includes dry etching.

20. (Previously presented) A method according to claim 17, wherein during the etching process a plurality of planar cutting elements inclined at an acute angle to the surface plane and having a sharp edge substantially at the surface plane are formed.

21. (Previously presented) A method according to claim 20, wherein the plurality of planar cutting elements comprises three planar cutting elements.

22. (Previously presented) A method according to claim 17, wherein the single crystal material is silicon.

23. (Previously presented) A method according to claim 17, wherein the etching process comprises isotropic etching.

24. (Previously presented) A method according to claim 17, wherein the etching process comprises wet etching.

25. (Cancelled)

26. (Currently Amended) A method according to claim 17, further comprising providing at least one intermediate transverse element connecting the cutting element and the guard element between the ~~supporting~~ interconnecting elements during the etching process.